# GSS User's Guide Ver 0.46.07 

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## 1 Introduction

### 1.1 The format of input card

Like PISCES and MEDICI, GSS takes its command cards from a user specified disk file. The input is read by GSS's build-in command parser. Each line is recognized as a particular statement, identified by the first word (named as keyword) on the card. The remaining parts of the line are the parameters of that keyword. The statement has the format as follow:

KEYWORD [parameters]
The words on a line are separated by blanks or tabs. If more than one line of input is necessary for a particular statement, it may be continued on subsequent lines by placing a backslash sign ' $\backslash$ ' as the last non-blank character on the current line. Parameters may be one of four types: float, integer, bool or string. The float point number supports C style double precision real number. The bool value can be True, On, False and Off. String value is made up of lower line, dot, blank, number and alpha characters. The string should not begin with number and quotation marks are only needed if it contains blank. At last, the length of string is limited to 31 characters. All the parameter specification has the same format as

```
parameter_name = [number|integer|bool|string]
```

In the card descriptions, keywords and parameters are not case sensitive. But user input strings do, because file name may be specified by the string. Comments must begin with '\#' and can be either an separated line or locate at the end of current statement.

### 1.2 The sequence of input deck

Most of the cards GSS used are sequence insensitive. The order of occurrence of cards is significant in only two cases. The mesh generation cards must have the right order, or it can't work properly. GSS will execute the 'driven' cards sequently. So the placement order of 'driven' cards will affect simulation result.

### 1.3 Statement Description Format

## Syntax of Parameter Lists

The following special characters are used in the formatted parameter list:

```
Angle brackets < > - parameter type
Square brackets [ ] - optional group
Vertical bar | - alternate choice
Parentheses ( ) - group hierarchy
Braces { } - group hierarchy with high level
```


## Value Types

Besides some string parameters which have fixed values, most of the parameters need a user defined value. A lower case letter in angle brackets represents a value of a given type. The following types of values are represented:

```
<n> - double precision numerical value
<i> - integer value
<b> - bool value
<s> - string value
```


## 2 Global Specification

### 2.1 SET

## Description

Some global definitions such as the unit scale and environment temperature must be set before the initiation of GSS's build-in data. The SET command will do the definition.

## Syntax

set Carrier=( $\mathrm{p}|\mathrm{n}| \mathrm{pn}$ )
set Z.Width=<n>
set LatticeTemp=<n>
set DopingScale=<n>

| parameter | type <br> Carrier | default <br> string | pn | - |
| :---: | :---: | :---: | :---: | :--- | | description |
| :--- |
| The Carrier parameter specifies whether sin- | gle or dual carriers will be modeled during the simulation. But at present, GSS only supports dual carriers, so the parameter value must always be "pn"

Z.Width number $1 \quad \mu \mathrm{~m} \quad$ Z.Width is needed by current calculation. Because GSS is a two-dimensional simulator, the length in Z direction must be given if GSS simulates transistor with external circuit.
LatticeTemp number 300 K LatticeTemp defines external temperature.
DopingScale number $1 \mathrm{e} 18 \mathrm{~cm}^{-3}$ DopingScale will effect GSS's inner unit scale procedure which shows great influence to the convergence of nonlinear solver. In most case, set this value to $\max (\mathrm{Nd}, \mathrm{Na})$ is a good choice. But sometimes, a smaller value may be better.

## Example

```
set Carrier = pn # specify carrier type.
set Z.Width = 2 # device width in Z dimension. Unit:um
set LatticeTemp = 3e2 # specify initial temperature of device. Unit:K
set DopingScale = 1e16 # set carrier scale reference value
```


## 3 Mesh Generation

### 3.1 Introduction

The early version of GSS was designed as a pure solver. It uses CGNS(CFD General Notation System) as semiconductor device model file. This file format provides the ability to store grid, solution data, material information, boundary condition and connectivity in a single, well-defined and easy-to-use form. More important, CGNS has been accepted and supported by most of the commercial CFD corporations. So users have various ways to create their models. For example, models can be created by SGFramework, converted from MEDICI TIF file by TIFTOOL (shipped with GSS) or generated by ICEMCFD, which is a commercial CFD pre-processor.

Until very recently, the PISCES like model description language had been introduced to GSS. The mesh generation arithmetic works as follows. First, GSS builds the rectangle skeleton mesh by the model description statements; Then, GSS employs Triangle (developed by Jonathan Richard Shewchuk) to form the triangulate mesh and output the mesh to an initial CGNS file. At last, GSS reads the CGNS file again, computes the doping profile and finishes the remaining calculations.

Triangle uses delaunay arithmetic, which forms a high quality isotropic mesh. At the same time, MEDICI uses quadtree arithmetic to generate its mesh, which often gives a regular mesh but the mesh quality may be poor near the irregular boundary.

### 3.2 Coordinate System

The mesh generator uses a Cartesian coordinate system, in which the top horizontal line has the maximal y coordinate and left vertical line has the minimal x coordinate.

Note: This setting is different from PISCES and its commercial versions like MEDICI and ATLAS.

### 3.3 MESH

This statement indicates the beginning of the mesh generator.

## Syntax

| parameter | type | default | unit | description |
| :---: | :---: | :---: | :---: | :---: |
| Type | string | - | - | Type indicates which mesh generator is to be used. But at present it is useless since GSS only has one mesh generator. |
| ModelFile | string | - | - | ModelFile gives the name of temporary CGNS file. |
| Triangle | string | pzq30AD | - | Triangle passes parameters to Triangle code. The detailed description of this string can be found at Triangle's home page http://www.cs.cmu.edu/ quake/triangle.html. |

## Example

### 3.4 XMESH and YMESH

The XMESH and YMESH cards specify the location of lines of nodes in a rectangular mesh. The original mesh can be modified by following mesh cards like ELIMINATE and SPREAD.

## Syntax

$$
\begin{array}{ll}
\text { XMESH } & \{\text { WIDTH }=\langle n>|(X . M I N=<n>X . M A X=<n>)\} \\
& \{\text { N.SPACES }=<i>[\text { RATIO }=<n>] \mid H 1=<n>[H 2=<n>]\} \\
\text { YMESH } & \{\text { DEPTH }=\langle n>|(Y . M A X=<n>\text { Y.MIN }=<n>)\} \\
& \{\text { N.SPACES=<i> }[\text { RATIO }=<n>] \mid H 1=<n>[H 2=<n>]\}
\end{array}
$$

| parameter | type | default | unit | description |
| :---: | :---: | :---: | :---: | :---: |
| WIDTH | number | - | $\mu \mathrm{m}$ | The distance of the grid section in x direction. |
| DEPTH | number | - | $\mu \mathrm{m}$ | The distance of the grid section in y direction. |
| X.MIN | number |  | $\mu \mathrm{m}$ | The x location of the left edge of the grid section. synonym: X.LEFT. The value of X.MIN will be set to right edge of the previous grid section automatically. |
| X.mAX | number | - | $\mu \mathrm{m}$ | The x location of the right edge of the grid section. synonym: X.RIGHT. |
| Y.MIN | number | - | $\mu \mathrm{m}$ | The $y$ location of the bottom edge of the grid section. synonym: Y.BOTTOM. |
| Y.MAX | number | - | $\mu \mathrm{m}$ | The y location of the top edge of the grid section. synonym: Y.TOP. The value of Y.MAX will be set to bottom edge of the previous grid section automatically. |
| N.SPACES | integer | 1 | - | The number of grid spaces in the grid section. |
| RATIO | number | 1.0 | - | The ratio between the sizes of adjacent grid spaces in the grid section. RATIO should usually lie between 0.667 and 1.5 . |
| H1 | number | - | $\mu \mathrm{m}$ | The size of the grid space at the begin edge of the grid section. |
| H2 | number | - | $\mu \mathrm{m}$ | The size of the grid space at the end edge of the grid section. |

## Example

| XMESH | X.MIN $=0.0$ | X.MAX=0.50 | N. SPACES=8 |
| :--- | :--- | :--- | :--- |
| YMESH | DEPTH $=0.1$ | N.SPACES=8 | RATIO=0.8 |
| YMESH | DEPTH $=0.1$ | N.SPACES $=20$ |  |
| YMESH | DEPTH $=0.6$ | $H 1=0.005$ | $H 2=0.050$ |

### 3.5 ELIMINATE

The ELIMINATE statement eliminates mesh points along planes in a rectangular grid over a specified volume. This statement is useful for eliminating nodes in regions of the device structure where the grid is more dense than necessary. Points along every second line in the chosen direction within the chosen range are removed, except the first and last line. Successive eliminations of the same range remove points along every fourth line, eighth line, and so on.

## Syntax

| ELIMINATE | $\{$ DIRECTION $=($ ROWS \| COLUMNS) $\}$ |
| ---: | :--- |
|  | $[\{X . M I N=<n>\mid \operatorname{IX} . M I N=<i>\}][\{X . M A X=<n>\mid I X . M A X=<i>\}]$ |
|  | $[\{Y . M I N=<n>\mid I Y . M A X=<i>\}][\{Y . M A X=<n>\mid I Y . M I N=<i>\}]$ |


| parameter <br> DIRECTION | type <br> string | default <br> X.MIN | number | XMIN |
| :---: | :---: | :---: | :---: | :---: |$\quad$| nm |
| :--- |
| X.MAX | number | description |
| :--- |
| Specifies that horizontal or vertical lines of |
| nodes are eliminated. |
| The minimum x location of the rectangular |
| volume in which nodes are eliminated. syn- |
| onym: X.LEFT. |

## Example

| ELIMINATE | Direction=COLUMNS | Y.TOP=-1.0 |
| :--- | :--- | :--- |
| ELIMINATE | Direction=ROWS | IX.MAX=8 |

### 3.6 SPREAD

The SPREAD statement provides a way to adjust the y position of nodes along grid lines parallel to the x -axis in a rectangular mesh to follow surface and junction contours.

## Syntax

```
            SPREAD LOCATION=(LEFT|RIGHT) WIDTH=<n> UPPER=<i> LOWER=<i> [ENCROACH=<n>]
                    { Y.LOWER=<n> | (THICKNES=<n> [VOL.RAT=<n>]) }
                    [GRADING=<n>]
```

| parameter | type | default | unit | description <br> LOCATION <br> string |
| :---: | :---: | :---: | :---: | :--- |
| WIDTH | - | - | Specifies which side of the grid is distorted. <br> number | 0.0 |$\quad \mu \mathrm{~m} .$| The width of the distorted region measured |
| :--- |
| from the left or right edge of the structure. |


| UPPER | integer | 0 | - | The index of the upper y-grid line of the dis- <br> torted region. |
| :--- | :--- | :--- | :--- | :--- |
| LOWER | integer | 0 | - | The index of the lower y-grid line of the dis- | torted region.

ENCROACH number 1.0 - The factor which defines the abruptness of the transition between distorted and undistorted grid. The transition region becomes more abrupt with smaller ENCROACH factors. The minimum allowed value is 0.1 .
Y.LOWER number - $\quad \mu \mathrm{m}$ The vertical location in the distorted region where the line specified by LOWER is moved. The grid line specified by UPPER does not move if this parameter is specified.
THICKNESS number - $\quad \mu \mathrm{m}$ The thickness of the distorted region. Specifying THICKNESS usually causes the positions of both the UPPER and LOWER grid lines to move.
VOL.RAT number 0.44 - The ratio of the displacement of the lower grid line to the net change in thickness. If VOL.RAT is 0 , the location of the lower grid line does not move. If VOL.RAT is 1 , the upper grid line does not move.
GRADING number $1.0 \quad$ - $\quad$ The vertical grid spacing ratio in the distorted region between the $y$-grid lines specified with UPPER and LOWER The spacing grows or shrinks by GRADING in each interval between lines. GRADING should usually lie between 0.667 and 1.5.

## Example

```
SPREAD Location=Left Width=0.625 Upper=0 Lower=2 Thickness=0.1
```

SPREAD Location=Right Width=0.625 Upper=0 Lower=2 Thickness=0.1

### 3.7 REGION

The REGION statement defines the location of materials in the mesh. Currently, GSS supports following materials: null space including Vacuum and Air; semiconductor material including Si , Ge, GaAs, $\mathrm{Si}_{1-x} \mathrm{Ge}_{x}, \mathrm{Al}_{x} \mathrm{Ga}_{1-x} \mathrm{As}$ and $\mathrm{In}_{x} \mathrm{Ga}_{1-x} \mathrm{As}$; insulator material including $\mathrm{SiO}_{2}$ and electrode region including Elec, Al and PolySi.

## Syntax

```
REGION Shape=Rectangle Label=<s> Material=<s>
    [ X.MOLE=<n> [ MOLE.SLOPE=<n> | MOLE.END=<n> ] MOLE.GRAD=(X.Linear|Y.Linear)]
    [ {X.MIN=<n> | IX.MIN=<n>} ] [ {X.MAX=<n> | IX.MAX=<n>} ]
    [ {Y.MIN=<n> | IY.MIN=<n>} ] [ {Y.MAX=<n> | IY.MAX=<n>} ]
REGION Shape=Ellipse Label=<s> Material=<s>
    {CentreX=<n> CentreY=<n> MajorRadii=<n> MinorRadii=<n> Theta=<n> Division=<i>}
```

| parameter | type <br> Shape <br> string | default <br> - | unit |
| :---: | :---: | :---: | :---: |
| Label | string | - | - |
| Material | string | - | - |
| X.MOLE | number | 0.0 | - |
| MOLE.SLOPE | number | 0.0 | $\mu \mathrm{~m}^{-1}$ |

## description

Specifies the shape of the region. Can be Rectangle or Ellipse.
Specifies the identifier of this region, limited to 12 chars. Specifies the material of the region. Material strings can be Vacuum, Air, Si, Ge, GaAs, SiGe, AlGaAs, InGaAs, SiO 2 , Elec, Al and PolySi.
The mole fraction to use in the region for compound materials. For graded compounds, X.MOLE represents the initial mole fraction at the left, top, or front edge of the region depending on whether X.Linear, or Y.Linear, respectively, is specified.
MOLE.SLOPE number

| MOLE.END | number | 0.0 | - | The mole fraction for graded compounds at the right, bottom, or backedge of the region depending on whether X.Linear, or Y.Linear, respectively, is specified. |
| :---: | :---: | :---: | :---: | :---: |
| MOLE.GRAD | string | Y.Linear |  | Specifies that the mole fraction grading is in the x or y direction. |
| X.MIN | number | XMIN | $\mu \mathrm{m}$ | The minimum x location of the region. synonym: X.LEFT. |
| X.mAX | number | XMAX | $\mu \mathrm{m}$ | The maximum x location of the region. synonym: X.RIGHT. |
| IX.MIN | integer | 0 | - | The minimum x node index of the region. synonym: IX.LEFT. |
| IX.MAX | integer | IXMAX-1 | - | The maximum x node index of the region. synonym: IX.RIGHT. |
| Y.MIN | number | YMIN | $\mu \mathrm{m}$ | The minimum y location of the region. synonym: Y.BOTTOM |


| Y.MAX | number | YMAX | $\mu \mathrm{m}$ | The maximum y location of the region. synonym: Y.TOP. |
| :---: | :---: | :---: | :---: | :---: |
| IY.MIN | integer | 0 |  | The minimum y node index of the region. synonym: IY.TOP |
| IY.MAX | integer | IYMAX-1 | - | The maximum y node index of the region. synonym: IY.BOTTOM. |
| CentreX | number | 0.0 | $\mu \mathrm{m}$ | The x location of the center of ellipse. |
| CentreY | number | 0.0 | $\mu \mathrm{m}$ | The y location of the center of ellipse. |
| MajorRadii | number | 1.0 | $\mu \mathrm{m}$ | The length of the major radii of ellipse. |
| MinorRadii | number | MajorRadii | $\mu \mathrm{m}$ | The length of the minor radii of ellipse. |
| Theta | number | 0.0 | degree | The angle of the first division point located on the boundary of ellipse region. |
| Division | integer | 12 | - | The number of points which divide the boundary of ellipse into small segments. |

## Example

| REGION | Label=Si1 | Material=Si | Y.TOP $=0.000$ | Y. BOTTOM $=-0.100$ |
| :--- | :--- | :--- | :--- | :--- |
| REGION | Label=SiGe1 | Material=SiGe | Y.TOP=-0.100 | Y.BOTTOM=-0.125 |
|  | X.MOLE=0.0 | Mole.End=0.2 |  |  |

## Hint

Several regions can be defined one by one. But users should be careful that regions can't get cross each other. The situations showed by Fig1 (A) and (B) are allowed, but (C) will break the mesh generator of GSS. The ellipse region is used for photon crystal simulation. By choosing different division number, GSS can build triangle, rectangle, hexagon as well as ellipse (circle). Fig2 shows different shapes of polygons build by ellipse.



Figure 2: Define shapes of ellipse region

### 3.8 SEGMENT

Segment is a group of boundary edges which have the same attribute. This statement specifies the label of a special segment. User can assign the segment with a special boundary type by BOUNDARY statement.

## Syntax

```
SEGMENT Label=<s> { Location=<s> | ( Direction=<s> X=<n> | Y=<n> ) }
    [ {X.MIN=<n> | IX.MIN=<n>} ] [ {X.MAX=<n> | IX.MAX=<n>} ]
    [ {Y.MIN=<n> | IY.MIN=<n>} ] [ {Y.MAX=<n> | IY.MAX=<n>} ]
```

| parameter | type | default | unit | description |
| :---: | :---: | :---: | :---: | :---: |
| Label | string | - | - | Specifies the identifier of this segment, limited to 31 chars. |
| Location | string |  |  | Specifies which side the segment lies along. Allowed: TOP, BOTTOM, LEFT or RIGHT. |
| Direction | string | - | - | Specifies the dimensional orientation of the segment. Allowed: Horizontal or Vertical. |
| X | number | 0.0 | $\mu \mathrm{m}$ | Specifies the X coordinate of the vertical segment. |
| Y | number | 0.0 | $\mu \mathrm{m}$ | Specifies the Y coordinate of the horizontal segment. |
| X.MIN | number | XMIN | $\mu \mathrm{m}$ | The minimum x location of the segment. synonym: X.LEFT. |
| X.mAX | number | XMAX | $\mu \mathrm{m}$ | The maximum x location of the segment. synonym: X.RIGHT. |
| IX.MIN | integer | 0 | - | The minimum x node index of the segment. synonym: IX.LEFT. |
| IX.MAX | integer | IXMAX-1 | - | The maximum x node index of the segment. synonym: IX.RIGHT. |
| Y.MIN | number | YMIN | $\mu \mathrm{m}$ | The minimum y location of the segment. synonym: Y.BOTTOM. |
| Y.mAX | number | YMAX | $\mu \mathrm{m}$ | The maximum y location of the segment. synonym: Y.TOP. |
| IY.MIN | integer | 0 | - | The minimum y node index of the segment. synonym: IY.TOP. |
| IY.MAX | integer | IYMAX-1 | - | The maximum y node index of the segment. synonym: IY.BOTTOM. |

## Example

| SEGMENT | Label=Anode | Direction=Horizontal X.MIN=0.0 X.MAX=1.0 Y=0.0 |
| :--- | :--- | :--- | :--- | :--- |
| SEGMENT | Label=Cathode | Direction=Horizontal X.MIN=0.0 X.MAX=3.0 Y=-3.0 |
| SEGMENT | Label=Anode | Location=TOP X.MIN=0.0 X.MAX=1.0 |
| SEGMENT | Label=Cathode | Location=BOTTOM |

## Hint

Here, I have to mention the naming principle of segments. Beside labeled segments, the interface edges between two regions will be assigned by IF _name1 _to_name2 in which the name1 and name2 is the labels of the two regions by alpha order. The remain edges of a region will be assigned by name_Neumann and the name is the label of the region.

One can define a segment for probing data. Please refer to PROBE statement. This kind of segment should be placed inside a region. Equally, NO intersection to any other segment.

### 3.9 REFINE

The REFINE statement allows refinement of a coarse mesh.

| Syntax |  |  |  |  |
| :---: | :---: | :---: | :---: | :---: |
| REFINE | ```Variable=(Doping\|Potential) Dispersion=<n> DivisionRatio=<n> [ Measure=(Linear|SignedLog) ] [ Triangle=<s> ]``` |  |  |  |
| parameter | type | default | unit | description |
| Variable | string | - | - | Specifies that the grid refinement is based on the potential or doping quantity. |
| Measure | string | Linear |  | Specifies that refinement is based on the original value or logarithm of the specified quantity. |
| Dispersion | number | 3.0 |  | The numerical criterion for refining a triangle. If the specified quantity differs by more than this parameter at the nodes of a triangle, the triangle is divided. |
| DivisionRatio | number | 0.25 |  | The area of divided triangle over area of original triangle. The default value suggests Triangle code divide one triangle into 4 small triangles. It is a suggestion value, Triangle code will adjust it for mesh quality reason. |
| Triangle | string | praq30Dz | - | Passes parameters to Triangle code. |

## Example

REFINE Variable=Doping Measure=SignedLog Dispersion=1 REFINE Variable=Potential Measure=Linear Dispersion=0.1


Figure 3: Mesh refinement for a PN diode.

## 4 Doping Profile

The PROFILE statement defines profiles for impurities to be used in the device structure. At present, GSS supports analytic profiles such as uniform, gauss distribution in both x-y directions and error function distribution in x direction while gauss distribution in y direction.

## Syntax

| PROFILE \{ Type=Uniform |  |
| :---: | :---: |
| Type=Gauss | [YCHAR=<n> \| Y.Junction=<n>] [XCHAR=<n>] |
| Type=ErrorFun | [YCHAR=<n>] [XCHAR=<n>] \} |
| Ion=(Donor\|Acceptor) \{ N.Peak=<n> \| Dose=<n> \} |  |
| [ X.MIN=<n> ] [ | . MAX=<n> ] [ Y.MIN=<n> ] [ Y.MAX=<n> ] |


| parameter | type | default | unit | description |
| :---: | :---: | :---: | :---: | :---: |
| Type | string | - | - | Specifies that the profile has a uniform, gauss or error function distribution. |
| Ion | string | - |  | Specifies the impurity ionization. |
| N.Peak | number | 0.0 | $\mathrm{cm}^{-3}$ | The peak impurity concentration for an impurity profile. |
| Dose | number | 0.0 | $\mathrm{cm}^{-2}$ | The dose of the impurity profile assuming a full Gaussian distribution. |
| X.MIN | number | 0.0 | $\mu \mathrm{m}$ | The minimum x location of the doping profile. synonym: X.LEFT. |
| X.mAX | number | XMIN | $\mu \mathrm{m}$ | The maximum x location of the doping profile synonym: X.RIGHT. |
| Y.MIN | number | YMAX | $\mu \mathrm{m}$ | The minimum y location of the doping profile. synonym: Y.BOTTOM. |
| Y.MAX | number | 0.0 | $\mu \mathrm{m}$ | The maximum y location of the doping profile. synonym: Y.TOP. |
| YCHAR | number | 0.25 | $\mu \mathrm{m}$ | The y characteristic length of the profile outside the range of Y.MIN $<\mathrm{y}<$ Y.MAX. |
| XCHAR | number | 0.25 | $\mu \mathrm{m}$ | The x characteristic length of the profile outside the range of X.MIN $<\mathrm{x}<\mathbf{X}$.MAX. |
| Y.Junction | number | 0.0 | $\mu \mathrm{m}$ | The y location under the center of the profile where the magnitude of the profile being added equals the magnitude of the background profile. |

## Example

```
PROFILE Type=Uniform Ion=Donor N.PEAK=1E15 \
    X.MIN=0.0 X.MAX=3.0 Y.TOP=0.0 Y.BOTTOM=-3.0
PROFILE Type=Gauss Ion=Acceptor N.PEAK=1E18 X.CHAR=0.2 Y.JUNCTION=-0.5 \
    X.MIN=0.0 X.MAX=0.7 Y.TOP=0.0 Y.BOTTOM=0.0
PROFILE Type=ErrorFunc Ion=Acceptor N.PEAK=2E17 X.CHAR=0.25 Y.CHAR=0.25 \
    X.MIN=0.5 X.MAX=1.0 Y.TOP=0.0 Y.BOTTOM=0.0
```


## 5 Voltage and Current Source

### 5.1 Introduction

For simulation the transient response of device, GSS supports several types of voltage and current source. The original models of these sources come from SPICE, a famous circuit simulation program. Several sources may be defined in one disk file. And the placement of these definitions are not critical. The sources can be assigned to electrode by ATTACH statement when needed.

### 5.2 ISOURCE

## Syntax

```
isource Type=IDC ID=<s> Tdelay=<n> Iconst=<n>
isource Type=ISIN ID=<s> Tdelay=<n> Iamp=<n> Freq=<n>
isource Type=IEXP ID=<s> Tdelay=<n> TRC=<n> TFD=<n>
    TFC=<n> Ilo=<n> Ihi=<n>
isource Type=IPULSE ID=<s> Tdelay=<n> Tr=<n> Tf=<n>
    Pw=<n> Pr=<n> Ilo=<n> Ihi=<n>
isource Type=ISHELL ID=<s> DLL=<s> Func=<s>
```

| parameter | type | default | unit | description |
| :---: | :---: | :---: | :---: | :---: |
| Type | string | - | - | This parameter declares which type of current source is defined here. Only four types of current source listed as previous are supported at present. |
| ID | string | - | - | A unique string which identifies the current source. |
| Tdelay | number | 0 | s | A proper delay time before the activation of this current source. |
| Iconst | number | 0 | mA | The current of the IDC. |
| Iamp | number | 0 | mA | The amplitude current of the ISIN. |
| Freq | number | 0 | Hz | The frequency of the ISIN. |
| TRC | number | 0 | s | The rise time constant of the IEXP. |
| TFD | number | 0 | s | The fall delay time of the IEXP. |
| TFC | number | 0 | s | The fall time constant of the IEXP. |
| Tr | number | 0 | s | The raise edge of the IPULSE. |
| Tf | number | 0 | s | The fall edge of the IPULSE. |
| Pw | number | 0 | s | The pulse with of the IPULSE. |
| Pr | number | 0 | s | The period of the IPULSE. |
| Ilo | number | 0 | mA | The low current for both IEXP and IPULSE. |
| Ihi | number | 0 | mA | The high current for both IEXP and IPULSE. |
| DLL | string | - | - | The name of dynamic library file. |
| Func | string | - | - | The name of the function loaded from dynamic library file. |

## Example

```
isource Type=IDC ID=I1 Tdelay=0 Iconst=5
isource Type=ISIN ID=I2 Tdelay=0 Iamp=0.1 Freq=1e6
isource Type=IEXP ID=I3 Tdelay=0 TRC=1E-6 TFD=3E-6 TFC=1E-6 Ilo=0 Ihi=1
isource Type=IPULSE ID=I4 Tdelay=0 Tr=1E-9 Tf=1E-9 Pw=5E-6 Pr=1E-5 Ilo=0 Ihi=1
```


### 5.3 VSOURCE

## Syntax

```
vsource Type=VDC ID=<s> Tdelay=<n> Vconst=<n>
vsource Type=VSIN ID=<s> Tdelay=<n> Vconst=<n> Vamp=<n> Freq=<n> Alpha=<n>
vsource Type=VEXP ID=<s> Tdelay=<n> TRC=<n> TFD=<n>
    TFC=<n> Vlo=<n> Vhi=<n>
vsource Type=VPULSE ID=<s> Tdelay=<n> Tr=<n> Tf=<n>
    Pw=<n> Pr=<n> Vlo=<n> Vhi=<n>
vsource Type=VSHELL ID=<s> DLL=<s> Func=<s>
```

parameter type default unit description
Type string - - This parameter declares which type of voltage
source is defined here. Only four types of volt-
age source listed as previous are supported at
present.

| ID | string | - | - | A unique string which identifies the voltage source. |
| :---: | :---: | :---: | :---: | :---: |
| Tdelay | number | 0 | S | A proper delay time before the activation of this voltage source. |
| Vconst | number | 0 | V | The voltage of the VDC. |
| Vamp | number | 0 | V | The amplitude voltage of the VSIN. |
| Freq | number | 0 | Hz | The frequency of the VSIN. |
| Alpha | number | 0 | - | The exponential attenuation parameter of the VSIN. |
| TRC | number | 0 | S | The rise time constant of the VEXP. |
| TFD | number | 0 | S | The fall delay time of the VEXP. |
| TFC | number | 0 | S | The fall time constant of the VEXP. |
| Tr | number | 0 | S | The raise edge of the VPULSE. |
| Tf | number | 0 | S | The fall edge of the VPULSE. |
| Pw | number | 0 | S | The pulse with of the VPULSE. |
| Pr | number | 0 | S | The period of the VPULSE. |
| Vlo | number | 0 | V | The low voltage for both VEXP and VPULSE. |
| Vhi | number | 0 | V | The high voltage for both VEXP and VPULSE |

DLL string - - The name of dynamic library file.
Func string - - The name of the function loaded from dy-
namic library file.

## Example

```
vsource Type=VDC ID=GND Tdelay=0 Vconst=0
vsource Type=VDC ID=VCC Tdelay=0 Vconst=5
vsource Type=VSIN ID=Vs Tdelay=1e-6 Vamp=0.1 Freq=1e6
vsource Type=VEXP ID=V1 Tdelay=0 TRC=1e-6 TFD=1e-6 TFC=1e-6 Vlo=0 Vhi=1
vsource Type=VPULSE ID=V2 Tdelay=0 Tr=1e-9 Tf=1e-9 Pw=5e-6 Pr=1e-5 Vlo=0 Vhi=1
vsource Type=VSHELL ID=VGauss DLL=foo.so Func=vsrc_gauss
```


## Hint

GSS supports user defined voltage and current source by loading shared object (.so) file. The file which contains a user defined voltage source should have the function as follow. GSS will pass the argument time in the unit of second to the function vsrc_name and get voltage value in the unit of volt. The current source function is almost the same except the unit of current is mA .

```
double vsrc_name(double time)
{
    /* calculate the voltage amplitude */
    return vsrc_amplitude;
}
double isrc_name(double time)
{
    /* calculate the current amplitude */
    return isrc_amplitude;
}
```

The c code should be linked with -shared and -fPIC option as:

```
gcc -shared -fPIC -o foo.so foo.c -lm
```

The foo.so file should be put in the same directory as input file.

## 6 Boundary Condition

### 6.1 BOUNDARY and CONTACT

The BOUNDARY statement sets boundary information to representing segments which defined by mesh generator or read from CGNS file.

GSS now fully support electrode region (the material of this region may be metal or polySi). One should use CONTACT statement to specify the electrode type of this region(s).

## Syntax



| parameter <br> Type | type <br> string | default <br> - | unit <br> - | description <br> This parameter declares which type of bound- <br> ary condition is defined here. |
| :---: | :---: | :---: | :---: | :--- |
| ID | string | - | - | A unique string which identifies the corre- <br> sponding segment. |
| Res | number | 0 | $\Omega$ | The lumped resistance for the electrode. |
| Cap | number | 0 | F | The lumped capacitance for the electrode. |
| Ind | number | 0 | H | The lumped inductance for the electrode. <br> ConnectTo <br> string |
|  | - | - | Specifies the ID of an ohmic electrode which <br> connect to this ohmic electrode. Useful for |  |
|  |  |  | CMOS structure. |  |


| WorkFunction | number | 4.7 | V | The workfunction of the Schottky contact or <br> gate material. |
| :---: | :---: | :---: | :---: | :--- |
| QF | number | 0 | $\mathrm{C} \cdot \mathrm{cm}^{-2}$ | For InsulatorContact and InsulatorInter- <br> face bc: The surface charge density of <br> semiconductor-insulator interface. |
| QF | number | 0 | $\mathrm{C} \cdot \mathrm{cm}^{-2}$ | For Heterojunction bc: The surface charge <br> density of heterojunction. |
| QF | number | 0 | $\mathrm{C} \cdot \mu \mathrm{m}^{-1}$ | For FloatMetal bc: The free charge per micron <br> in Z dimension. |
| Thickness | number | $2 \mathrm{e}-7$ | cm | The thickness of $\mathrm{SiO}_{2}$ layer. |
| Eps | number | 3.9 | - | The relative permittivity of $\mathrm{SiO}_{2}$ layer. |
| EXT.Transfer | number <br> number | LatticeTemp | $\mathrm{W} /(\mathrm{cm} \cdot \mathrm{K})$ | The heat transfer rate of boundary. <br> The external temperature. |

## Example

```
BOUNDARY Type=InsulatorContract ID=SiSiO2 Res=0 Cap=0 Ind=0 \
    Thickness=1e-6 Eps=3.9 WorkFunction=4.7 QF=0
BOUNDARY Type=InsulatorInterface ID=IFACE QF=0
BOUNDARY Type=GateContract ID=GATE Res=0 Cap=0 Ind=0 WorkFunction=4.7
BOUNDARY Type=NeumannBoundary ID=WALL Heat.Transfer=0 EXT.Temp=300
BOUNDARY Type=SchottkyContract ID=sgate Res=0 Cap=0 Ind=0 VBarrier=0.8
BOUNDARY Type=OhmicContract ID=OMANODE Res=0 Cap=0 Ind=0
BOUNDARY Type=OhmicContract ID=OMCATHODE Res=0 Cap=0 Ind=0
```


## Hint

Four "electrode" boundary conditions are supported by GSS. The names are ended with "Contact". The OhmicContact and SchottkyContact electrodes have current flow in both steady state and transient situations. While GateContact and InsulatorContact(a simplified MOSFET Gate boundary condition) only have displacement current in transient situation.

GSS supports five interfaces which can be set automatically: semiconductor-insulator interface(InsulatorInterface), semiconductor-electrode interface(set to OhmicContract as default), interface between different semiconductor material(Heterojunction) and interface between same semiconductor material(Homojunction). These boundaries can be set automatically by GSS if user didn't set them explicitly. However, the electrode-insulator interface, may have several situations: Gate to Oxide interface, FloatMetal to Oxide interface or Source/Drain electrode to Oxide interface. As a result, this interface can only be set correctly when electrode type is known. Please refer to the following CONTACT statement.

GSS can build region with metal or poly-Si material to form an electrode. Which means, i.e. for OhmicContact bc, one can simply specify a segment as Ohmic bc or build an electrode region as Ohmic electrode. Since Version 0.45.03, GSS considers electrode region, semiconductor region and insulator region during calculation. As a result, GSS added CONTACT statement for fast boundaries specification of electrode region. At present, GSS support electrode with the type of Ohmic, Schottky, Gate and FloatMetal. All the electrode should be specified explicitly and GSS will set corresponding boundaries automatically.

The "ID" parameter of BOUNDARY statement is limited to segment label. And The "ID" parameter of CONTACT statement is limited to region name.

The NeumannBoundary, which is the default boundary type for all the non-interface segments, can also be set automatically.

### 6.2 ATTACH

This statement is used to add voltage or current sources to the electrode boundary. The statement first clears all the sources connected to the specified electrode and then adds source(s) defined by VApp or IApp parameter. If two or more sources are attached to the same electrode, the total effect is the summation of all sources. However, the sources attached to one electrode must have the same type.

## Syntax

| ATTACH Electrode=<s> | Type=Voltage VApp=<s> | $[V A p p=<s>\ldots]$ |
| :--- | :--- | :--- |
| ATTACH Electrode=<s> | Type=Current IApp=<s> $[$ IApp=<s> ...] |  |


| parameter | type | default | unit | description <br> Electrode |
| :---: | :---: | :---: | :---: | :--- |
| string | - | - | Specifies which electrode boundary is to be at- <br> tached with one or more sources. |  |
| Type | string | Voltage | - | The sources are voltage or current type. |
| VApp | string | - | - | Specifies the ID of voltage source which is to <br> be attached to this electrode. |
| IApp | string | - | - | Specifies the ID of current source which is to <br> be attached to this electrode. |

## Example

| ATTACH | Electrode=Collector | VApp=VCC |  |  |
| :--- | :--- | :--- | :--- | :--- |
| ATTACH | Electrode=Emitter | VApp=GND |  |  |
| ATTACH | Electrode=Base | VApp=Vb VApp=Vs |  |  |
| ATTACH | Electrode=Base | Type=Current IApp=Ib | IApp=Is |  |

## Hint

If electrode is attached with voltage source(s), the $R, C$ and $L$ defined by BOUNDARY statement will affect later simulation. But solver will ignore those lumped elements with the electrode which stimulated by current source(s). Please refer to Fig 4.

The positive direction of current is flow into the electrode.
Only Ohmic and Schottky electrodes can be attached by current source(s).
If no source attached explicitly, the electrode is set to be attached to ground.


Figure 4: Voltage and current boundary.

## 7 Physical Model Interface

GSS use a dynamic mechanician to support various materials and physical models. Each material has a dynamic load library (.so) which contains its physical parameters. User can modify the parameters which can be found at $\$($ GSS_DIR $) / \mathrm{src} /$ material and recompile it. Experts can even offer their own physical model files.

At present, GSS has a PMIS statement for choosing different mobility models and impact ionization models.

## Syntax

PMIS Region=<s> Mobility=<s> II.Model=<s>

| parameter <br> Region | type <br> string | default <br> unit | description <br> Specifies the semiconductor region which use |  |
| :---: | :---: | :---: | :---: | :--- |
| Mobility | string | Analytic | - | the following physical model. |
| II.Mo mobility model name. |  |  |  |  |

## Example

```
PMIS Region=Si Mobility=Philips
PMIS Region=Si Mobility=Lucent II.Model=Valdinoci
```


## Hint

One can set different physical models to individual region.
GSS has implemented Analytic, Philips and Lucent mobility model for all the supported material. The Analytic and Philips mobility model only takes parallel field effect and they can be used within all the four solvers. The author suggest to use these models for bipolar device simulations. The Lucent mobility model, which considers parallel and transverse electrical field, is an accurate model for MOS structure. But it should work with DDML1E/DDML2E solvers in which transverse electrical field is calculated. The Lombardi and HP (HewlettPackard) mobility model only validate for Silicon. These two mobility models include parallel and transverse electrical field corrections and can be used for MOSFET simulation. The Hypertang mobility model only validate for GaAs. It is reported that this model can avoid unrealistic drain current oscillation when applied to the simulation of GaAs MESFET.

The impact ionization model is still very limited in GSS. Only Valdinoci model for silicon is valid at present.

## 8 Solve Specification

### 8.1 Introduction

These statements instruct GSS core to perform user specified solution(s).

### 8.2 METHOD

The METHOD statement sets the solver and the parameters of the solver. At present, GSS 0.4 x has basic DDM solver(DDML1E), lattice temperature corrected DDM solver(DDML2E) and EBML3E solver which base on energy balance model.

## Syntax

```
METHOD Type=(DDML1E|DDMLE2|EBML3E|QDDML1E) Scheme=Newton
    HighFieldMobility=(On|Off) EJModel=(On|Off)
    ImpactIonization=(On|Off) II.Type=(EdotJ|EVector|ESide|GradQf)
    BandBandTunneling=(On|Off)
    Fermi=(On|Off)
    NS=(Basic|LineSearch|TrustRegion)
    LS=(SuperLU|LU|CGS|BICG|BCGS|GMRES|TFQMR)
    Damping=(BankRose|Potential|No)
    MaxIteration=<i> relative.tol=<n>
    possion.tol=<n> elec.continuty.tol=<n> hole.continuty.tol=<n>
    elec.energy.tol=<n> hole.energy.tol=<n> latt.temp.tol=<n>
    electrode.tol=<n> toler.relax=<n>
    QNFactor=<n> QPFactor=<n>
```

| parameter <br> Type | type <br> string <br> scheme | default <br> Dtring | unit | description <br> Newton |
| :---: | :---: | :---: | :---: | :--- |
| HighFieldMobility | bool | On | - | Specifies the solver. <br> At present, GSS only supports Newton's full <br> iterative scheme. |
| EJModel | bool | Off | - | Specifies if high field mobility should be used. <br> GSS set this flag to OFF for equilibrium state. |
| Specifies if EdotJ and EcrossJ should be use |  |  |  |  |
| to calculate high field mobility. GSS will use |  |  |  |  |
| a simpler model when this flag is set to OFF. |  |  |  |  |



## Example

| METHOD | Type=DDML1E | Scheme=Newton | NS=LineSearch $\quad$ LS=GMRES |
| :--- | :--- | :--- | :--- | :--- |
| METHOD | Type=DDML1E | Scheme=Newton | NS=TrustRegion LS=LU |
| METHOD | Type=DDML2E | Scheme=Newton | NS=Basic LS=TFGMR Damping=Potential |

## Hint

All the DDML1E/DDML2E/EBML3E/QDDML1E solvers support parallel and transverse electrical field dependent mobility.

Lattice temperature equation is considered by DDML2E solver. The EBML3E solver is based on advanced energy balance method. The QDDML1E is a density-gradient solver which consists of quantum correction to classical model.

The carrier generation by impact ionization and band band tunneling is really difficult for calculation. However, DDML1E/DDML2E solvers are carefully designed for impact ionization and band band tunneling calculation, i.e. diode reverse breakdown simulation. Usually, the temperature can't keep unchanged if carrier generation takes place. As a result, DDML2E solver is highly recommend for these types of situations. At present, EBML3E and QDDML1E solver don't support impact ionization.

Fermi statistics is only supported by DDML1E and DDML2E solvers.
LineSearch and TrustRegion accelerating methods work well when initial value a bit far from real solution, e.g. first time computing. Basic Newton method should only be used when initial value is near the true solution, e.g. dc sweep and transient calculation.

Each nonlinear solver should have a inner linear solver. To choose a suitable linear solver may help the convergence. The performance of LineSearch and Basic Newton methods is good when Krylov subspace linear solvers(CGS, BICG, BCGS, GMRES and TFQMR) are employed. However, the TrustRegion method prefers LU factorization linear solver to Krylov subspace linear solvers.

Newton Damping is a useful tool for helping convergence, especially for the Basic Newton method.

QNFactor and QPFactor is used to enforce the convergence property of QDDML1E solver. Since quantum solution differs much from classical solution near $\mathrm{Si} / \mathrm{SiO} 2$ interface, setting these two factors with small value i.e. 1e-4 and varying it gradually to 1.0 , with each step the solution can get convergence. At last, the value of QXFactor of 1.0 means that the quantum model is fully turned on and applied.

The parameters of METHOD statement will not be affected by previous METHOD statement.

The convergence is considered to be achieved when either the X norm or the function residual norm falls below certain tolerance. When every function's residual norm falls small than certain tolerance, the absolute convergence is achieved. For X norm criteria, it should fall below relative.tol and every function residual norm should fit the relaxed (with the relaxation value of toler.relax) absolute converged criteria.

### 8.3 SOLVE

The SOLVE statement instructs GSS to perform a solution for one or more specified bias points.

## Syntax



| parameter | type | default | unit | description |
| :---: | :---: | :---: | :---: | :---: |
| Type | string | - | - | Specifies the Solve condition. |
| VScan | string | - |  | Specifies the voltage variational electrode boundary for DCSWEEP. |
| VStart | number | - | V | The initial voltage for DC sweep. |
| VStep | number | - | V | The voltage step size of DC sweep. |
| VStop | number | - | V | The finish voltage for DC sweep. |
| IScan | string | - | - | Specifies the current variational electrode boundary for DCSWEEP. |
| IStart | number | - | mA | The initial current for DC sweep. |
| IStep | number | - | mA | The current step size of DC sweep. |
| IStop | number | - | mA | The finish current for DC sweep. |
| IV.Record | string | - | - | Specifies which electrode's IV data should be recorded. User can define serval electrodes here. |
| IV.File | string | - |  | Specifies the file which contains the IV data. |
| ODE.Formula | string | BDF2 |  | Specifies the time march scheme for solving the time-domain ordinary differential equation. |
| TStart | number | - | s | The initial time for transient calculation. |
| TStep | number | - | s | The time step size of transient calculation. |
| TStop | number | - | s | The finish time for transient calculation. |
| AutoStep | bool | - | True | Use automatically time step control based on LTE. |
| Predict | bool | - | True | Predict initial value for next time step |

## Example

```
SOLVE Type=EQUILIBRIUM
SOLVE Type=DCSWEEP VScan=Anode IVRecord=Anode IVRecord=Cathode \
IVFile=ivfp.txt VStart=0 VStep=1e-2 VStop=0.6
```

```
SOLVE Type=DCSWEEP IScan=Anode IVRecord=Anode IVRecord=Cathode \
    IVFile=ivfp2.txt IStart=0.02 IStep=1e-2 IStop=1
SOLVE Type=TRANSIENT IVRecord=Anode IVFile=iv.txt \
    TStart=0 TStep=1e-10 TStop=3e-8
```


## Hint

For equilibrium state calculation, all the electrodes are set to ground.
You can't do a DC sweep with current scan to GateContact and InsulatorContact.
When STEADYSTATE or DCSWEEP solve is performed, transient 0 value of the voltage(current) source will be used as the bias of each electrode.

One can do voltage DCSWEEP with multi-electrode by specifying two or more VScan parameter. The voltage will be assigned to each electrode during the simulation. This function is useful for Double Gate MOS simulation.

The step size for DCSWEEP calculation will automatically reduce to half size if last step diverged. Then it will be multiplied by 1.1 on each step until it reaches original step size.

TRANSIENT simulation now use automatically time step control based on LTE (local truncation error).

### 8.4 AC Sweep Solver

In addition to DC steady state and transient analysis, GSS now allows AC small-signal analysis as a post-processing step after a DC solution.

## Syntax

```
        METHOD Type=DDML1AC LS=(LU|CGS|BICG|BCGS|GMRES|TFQMR)
    HighFieldMobility=(On|Off) EJModel=(On|Off)
    ImpactIonization=(On|Off) II.Type=(EdotJ|EVector|ESide|GradQf)
    BandBandTunneling=(On|Off)
    Fermi=(On|Off)
        SOLVE Type=ACSWEEP ACScan=<s> [IVRecord=<s> ...]
    [IVFile=<s>] FStart=<s> FMultiple=<s> FStop=<n> VAC=<n>
```

| parameter | type | default | unit | description <br> ACScan |
| :---: | :---: | :---: | :---: | :--- |
| string | - | - | Specifies the electrode for ACSWEEP. <br> FStart | number |
| 1 e 6 | Hz | The initial frequency for AC sweep. <br> FMultiple | number | 1.1 |
| - | The multiplicative factor for incrementing fre- |  |  |  |
| quency. |  |  |  |  |

## Hint

This solver shared Jacobian Matrix with DDML1E solver. Which means one should call it directly after DDML1E, keeping all the parameters unchanged for METHOD statement. If a previous computed result is imported, call DDML1E to do a steady-state calculation again and run DDML1AC later.

The convergence may be difficult if frequency is very high, i.e. nearly cut off frequency, because of the poor condition number of Jacobian matrix.

### 8.5 EM FEM Solver

GSS has a electromagnetic solver based on finite element method. This solver calculates the distribution of electromagnetic field radiated by monochrome (light) wave. The photon generated carrier density in semiconductor region can be got at the same time.

## Syntax

| PHOTOGEN | WAVELEN=<n> INTENSITY=<n> [ANGLE=<n>] [phase.diff=<n>] [quan.eff=<n>] |  | $\mathrm{WTM}=<\mathrm{n}>\mathrm{WTE}=<\mathrm{n}>$ |
| :---: | :---: | :---: | :---: |
| METHOD | Type=EMFEM | [LS=LU] |  |
| SOLVE |  |  |  |
| LSOURCE | Type=UNIFORM | Tdelay=<n> Power=<n> |  |
| LSOURCE | Type=PULSE | Tdelay=<n> Tr=<n> Tf=<n> | $\mathrm{PW}_{\mathrm{w}}=<\mathrm{n}>\mathrm{Pr}=<\mathrm{n}>$ |
|  | Powerhi=<n> | Powerlo=<n> |  |
| LSOURCE | Type=LSHELL | DLL=<s> Func=<s> |  |

## Syntax for PHOTOGEN

| parameter | type | default | unit | description |
| :---: | :---: | :---: | :---: | :---: |
| WAVELEN | number | 0.532 | $\mu \mathrm{m}$ | The wavelength of incident monochrome wave. |
| INTENSITY | number | 1.0 | $\mathrm{W} \cdot \mathrm{cm}^{-2}$ | The power density of incident wave. |
| ANGLE | number | 90 | degree | The clockwise angle of the ray direction relative to the horizontal axis. |
| WTM | number | 1.0 | - | The percentage of intensity of TM model. |
| WTE | number | 0.0 | - | The percentage of intensity of TE model. |
| phase.diff | number | 0.0 | degree | The differentiation of phase angle between TE model and TM model. $\Delta \Phi=\Phi_{T M}-\Phi_{T E}$ |
| quan.eff | number | 1.0 | - | The quantum efficiency (which means electron-hole pares generated by one photon) of photon generation. |

## Syntax for LSOURCE

| paramete | type | default | unit | description |
| :---: | :---: | :---: | :---: | :---: |
| Type | string |  |  | The type of light source. |
| Tdelay | number | 0.0 | s | The delay time before the activation of the light source. |
| Tr | number | 1e-15 | s | The rise time of the intensity of the pulse-type light source. |
| Tf | number | 1e-15 | s | The fall time of the intensity of the pulse type light source. |
| Pw | number | 0 | s | The pulse width of the intensity of the pulse type light source. |
| Pr | number | 0 | s | The repetition period of the intensity of the pulse type light source. |
| Power | number | 1.0 | - | The multiply factor to photon generated carrier density. |
| Powerhi | number | 1.0 | - | The higher multiply factor to photon generated carrier density. |
| Powerlo | number | 0 | - | The lower multiply factor to photon generated carrier density. |

```
DLL string - - The name of dynamic library file.
Func string - - The name of the function loaded from dynamic li-
    brary file which calculates power coefficient.
```


## Hint

User need to build a vacuum region surrounding device and a PML region surrounding vacuum region. These two region should have a thickness of no less than one wave length.

The work flow of EMFEM solver shows as follows. GSS set its internal solver to EMFEM when meets METHOD command with EMFEM type. The actual solving action takes place when meets the next SOLVE command. GSS will search the first PHOTOGEN command in the input list, using the parameters in this command during the solve procedure. This PHOTOGEN command will be removed from input list after solving action. As a result, user can set multi PHOTOGEN statements and repeat SOLVE command for corresponding times to calculate several beams of monochrome wave, during which the photon generated carrier density will be added to previous result.

The iterative method such as GMRES usually leads to divergence when solving FEM problem. LU factorization is highly recommend.

EMFEM only gets the photon generated carrier density. User should set one LSOURCE to describe the time evolution of the light source. The actual photon generated carrier density used in semiconductor simulation is the original value multiplied with power coefficient specified within LSOURCE.

When DDML1E or DDML2E solver is loaded for further simulation, the photon generated carrier will be considered.

User can define their own light source by dynamic loaded library as voltage or current source. Here is a template.

```
foo.c:
    double lsrc_power(double time) /* in the unit of s */
    {
        double power;
    /* calculate the power of light source */
    return power;
    }
```


### 8.6 IV File Format

GSS can generate IV record file for DC sweep, transient and AC sweep calculations. Here is the file format for the three situations.

The file for DC sweep: The first line is begin with '\#', followed by the name of each electrode. The remain part is the potential and current for each electrode, each takes one column. The unit of potential is volt and the unit of current is mA.

The file for transient calculation is nearly the same as the file for DC sweep, besides that the first column is the time with the unit of ps.

The file for AC sweep has the same head as above. The remaining part is organized as follows: The first column is the frequency with the unit of MHz . Then the IV properties of each electrode. Each electrode takes six columns, the real, image and amplitude of potential, followed by three columns for current.

Note: the electrode potential may not equal to the application voltage if lumped elements take place.

## $9 \quad$ File I/O

### 9.1 Introduction

The IMPORT and EXPORT statements are used to read and write solutions from a CGNS or TIF file. A model CGNS file only contains semiconductor device structure while a core CGNS file has previous solution data besides device structure. The TIF (Technology Interchange Format) file is an ASCII file used by Synopsys Medici software which equivalence to core CGNS file. We offer a small code TIFTool which can open TIF file, view the mesh and solution data and convert it to CGNS file.

### 9.2 IMPORT and EXPORT

## Syntax

IMPORT CoreFile=<s> | ModelFile=<s>
EXPORT CoreFile=<s> [ AscFile=<s> ] [ VTKFile=<s> ]

| parameter | type | default | unit | description |
| :---: | :---: | :---: | :---: | :--- |
| CoreFile | string | - | - | Write/read device structure and solution data <br> to a CGNS file. |
| ModelFile | string | - | - | Read device structure from a CGNS file which <br> probably crated by SGframework or converted |
| AscFile | string | - | - | from Medici TIF file by TIFTool. |
| Write device structure and solution data to a |  |  |  |  |
| TIF file. At present, we can't make our TIF |  |  |  |  |

## Example

EXPORT CoreFile=init.cgns AscFile=init.tif
IMPORT ModelFile=pn.cgns
IMPORT CoreFile=pn.cgns

## Hint

VTK file is intended to be used for post process. User can use Paraview ${ }^{1}$, MayaVi or VisIt ${ }^{2}$ to open and view VTK file. Further more, CGNS file is also supported by VisIt.

[^0]
## 10 Post Process

### 10.1 Plot

The PLOT statement initializes the graphical display device for two and three dimensional plots of device characteristics(3D) and device meshes(2D).

## Syntax

```
PlotMesh [TIFF.Out=<s>]
Plot Variable=Mesh [PS.Out=<s>] [TIFF.Out=<s>]
    [Resolution=(RES.Low|RES.Middle|RES.High)]
Plot Variable=(Na|Nd|ElecDensity|HoleDensity|Potential|EFieldX|EFieldy|Temperature)
        [ Measure=(Linear|SignedLog) ]
        [ PS.Out=<s> ] [ TIFF.Out=<s> ] [ Resolution=(RES.Low|RES.Middle|RES.High) ]
        [ AzAngle=<n> ] [ ElAngle=<n> ] [ Style=(Scale|Color|GrayLevel) ]
```

| parameter | type <br> Variable <br> string | default | unit | description <br> This parameter specifies plot context. <br> PS.OUT |
| :---: | :---: | :---: | :---: | :--- |
| string |  |  |  |  |$\quad-\quad$| - |
| :--- |
| Specifies the postscript file name. The plot |
| window will be saved to it. |

## Example

```
PLOT Variable=Mesh PS.OUT=mesh.ps
PLOT Variable=Nd Resolution=RES.High AzAngle=240 ElAngle=40 Style=Scale
PLOT Variable=Potential Resolution=RES.Middle TIFF.out=potential.tiff\
AzAngle=240 ElAngle=40 Style=Color
```


## Hint

PlotMesh is an interactive GUI for mesh display only exist for X11 system.
The PLOT command can be used on both X11 and Win32 systems. The 3D plot can be rotated by mouse and terminated by ESC key press. If PS.OUT or TIFF.OUT argument is specified, the latest window image will be saved.

### 10.2 Probe

The PROBE statement is used to extract field data along a user defined segment. The segment can be a boundary or a segment pre-defined in the region. For the in-region segment, GSS will set it as Neumann boundary with no heat flux which takes not effect to simulation result.

## Syntax

Probe Variable=(Na|Nd|ElecDensity|HoleDensity|Potential|EFieldX|EFieldy|Temperature)
Region=<s> Segment=<s> ProbeFile=<s> Append=<b>

| parameter | type | default | unit | description |
| :---: | :---: | :---: | :---: | :--- |
| Variable | string | - | - | This parameter specifies probe context. |
| Region | string | - | - | Specifies the region name which the segment belongs to. |
| Segment | string | - | - | Specifies the segment name for probing the data. |
| ProbeFile | string | - | - | The file name for recording the data. |
| Append | bool | OFF | - | Specifies the data should be appended to the file. |

## Example

```
PROBE Variable=Nd Region=Si Segment=PB1 ProbeFile=Nd.txt Append=Off
PROBE Variable=Potential Region=Si Segment=PB2 ProbeFile=P.txt Append=On
```


## Hint

Each PROBE statement records one variable for the whole segment to a user-specified file. GSS pushes PROBE statement as the sequence of input text into a stack until a SOLVE statement is met. These PROBE statements record the data during solve process. After that, GSS will clear the stack. In short, PROBE only operates for next SOLVE process.

The file format for probe is show as follows:

```
#region_name segment_name
#node_num X Y
# 0 x0 y0
# 1 x1 y1
# ..............
#SOLVE_TYPE variable_name
[V/I/Time] v0 v1 v2 ...
```

The head of file is the segment information, including region name, segment name, total node number and the location of each node. The last line of head shows the solve type and variable name. The solve type can be "EQUILIBRIUM", "STEADYSTATE", "DCSWEEP_VSCAN", "DCSWEEP_ISCAN" and "TRANSIENT". For the last three types, GSS will record V/I/Time in the first column, respectively. The variable value for all the nodes are listed in the same line.

## 11 Convergence Problem

The core arithmetic of GSS is solving the large scale nonlinear equations arisen from semiconductor drift-diffusion model by Newton's Iterative method. There are three factors which affect the convergence of nonlinear solvers: the initial value, the Jacobian Matrix and the inner linear solver. One must ensure that the initial value is sufficiently near the real solution, the Jacobian Matrix is exact or at least nearly exact and the inner linear solver can give a suitable solution. When one of the three demands is not satisfied, the convergence problem may raise. However, several skills can help convergence.

If the first time running failed due to bad initial value, one can employ a transient solver to do a time evolved solution. Set time step to a few ps, and the solution on every step may get convergence. After some certain steps, the initial shock is damped and physical variables are forced to get close to real quantities. Then the steady-state solver may work and you can get the equilibrium solution.

Since version 0.46, GSS use automatically differentiation to calculate Jacobian matrix. In most situations, author can guarantee that Jacobian matrix is exact, except some rigorous situations when round-off error is un-neglectable. However, GSS offers alternative choice, the Matrix-Free method to set Jacobian Matrix by finite difference approximation. This choice can be invoked with the command line option -snes_mf_operator. The Matrix-Free method works well when impact ionization takes place, but it runs much slower than original method.

Sometimes the LineSearch method may failed due to bad search direction. If one get divergence message during DC sweep and transient simulation when using LineSearch method, one can try TrustRegion or basic Newton method.

Newton damping is a powerful tool to help convergence. It can work with LineSearch and Basic Newton solvers. GSS has two damping method, BankRose and Potential. Usually, damping Potential is better than BankRose.

The most difficult problem is the failure of inner linear solver. When the Jacobian Matrix is singular, problems may happen. Especially one sets electrodes with lumped resistor or current sources. If one get a convergence failed message for these situations, please check the problem by adding command line option -ksp_monitor to exam the convergence history. For more information, one can use -ksp_singmonitor to get the condition number of matrix (this works only with GMRES method).

The author suggests some method to overcome the problem. First, one may improve the condition number by enlarging the DopingScale, but this will increase numerical error. Second, one should carefully choose the linear solver.

Here is the introduction of the main linear solvers GSS can use. GMRES is a robust method for non-symmetric matrices. It must retain all the previous vectors during iterative. The implemented code often uses a "restart" method to avoid large memory requirement. Sometimes the solution breaks when restart too often. One can increase this restart steps by -ksp_gmres_restart $\langle n\rangle$ ( n is the restart steps, default 150) BiCG and CGS often have irregular convergence behavior. The irregular result may get things worse. Bi-CGSTAB is the improved method to BiCG and CGS, which avoids the irregular convergence patterns of BiCG/CGS while maintaining about the same speed of convergence. TFQMR avoids the irregular convergence behavior of BiCG. Also it avoids some breakdown situations of BiCG. When BiCG temporarily stagnates or diverges, TFQMR may still works. At last, LU factor-
ization is the basic method for solving linear systems. Besides build-in LU solver, PETSC can be compiled with external LU factorization package such as SuperLU and UMFPACK. This method works slow but usually more stable than iteration solver.

In conclusion, LU factorization is recommend for conquering the singular problem. But user can try GMRES with large restart steps, Bi-CGSTAB and TFQMR methods for better efficiency.

## 12 Memory and CPU requirement

Thanks to C++'s dynamic memory manege system, GSS can solve problems with any scale (at least, theoretically). The memory requirement is not a serious bottleneck. A very large problem which contains 100 K nodes only requires about 300 MB memory. This requirement is easy to be satisfied with modern computers.

Because the core arithmetic of GSS is solving nonlinear equations, which involves lots of solutions of linear system, the CPU time is related with linear solvers, which is $O\left(n^{3}\right)$ with LU solver and $O\left(n^{2}\right)$ with krylov iterative solver, in which $n$ is the problem scale.

Fig5 shows the CPU time vs node number with a PN diode simulation by BCGS method on a Xeon 3.6 GHz workstation. The time is approximate the square of problem scale. It only requires serial seconds when total node number less than 5000 . But CPU time raises to some minutes when node's number reach to 100 K .


Figure 5: CPU time vs problem scale

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